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In re the Application of

Inventors: Natau NISHINAGA, et al.

Art Unit 1765

Appln. No.: 09/511,912

Examiner M. Anderson

Filed: February 23, 2000

For: METHOD FOR FORMING A SINGLE CRYSTALLINE FILM

AMENDMENT

Assistant Commissioner of Patents  
Washington, D.C. 20231

RECEIVED  
JAN 23 2002  
TC 1700

Sir:

In response to the Office Action mailed October 18, 2001,  
please amend the above-identified application as follows:

IN THE CLAIMS:

Please add the following new claim:

--17. A method for forming a single crystalline film as  
defined in claim 1, wherein the single crystalline substrate and  
the atomic beams, molecular beams or chemical beams are of  
different materials.--